



Correction to: Plasma processed carbon thin films applied to dye-sensitized solar cells

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The authors regret an error in the Experimental section of the published article:

In the section “Carbon CE preparation”, the correct base pressure should be 5 mTorr.

The authors apologise for any inconvenience caused.

The online version of the original article can be found at <https://doi.org/10.1007/s10008-017-3736-7>

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